

Study of the readout chip and silicon sensor degradation for the CMS pixel upgrade

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Pixel detector building blocks

Hybrid detector

Sensor:

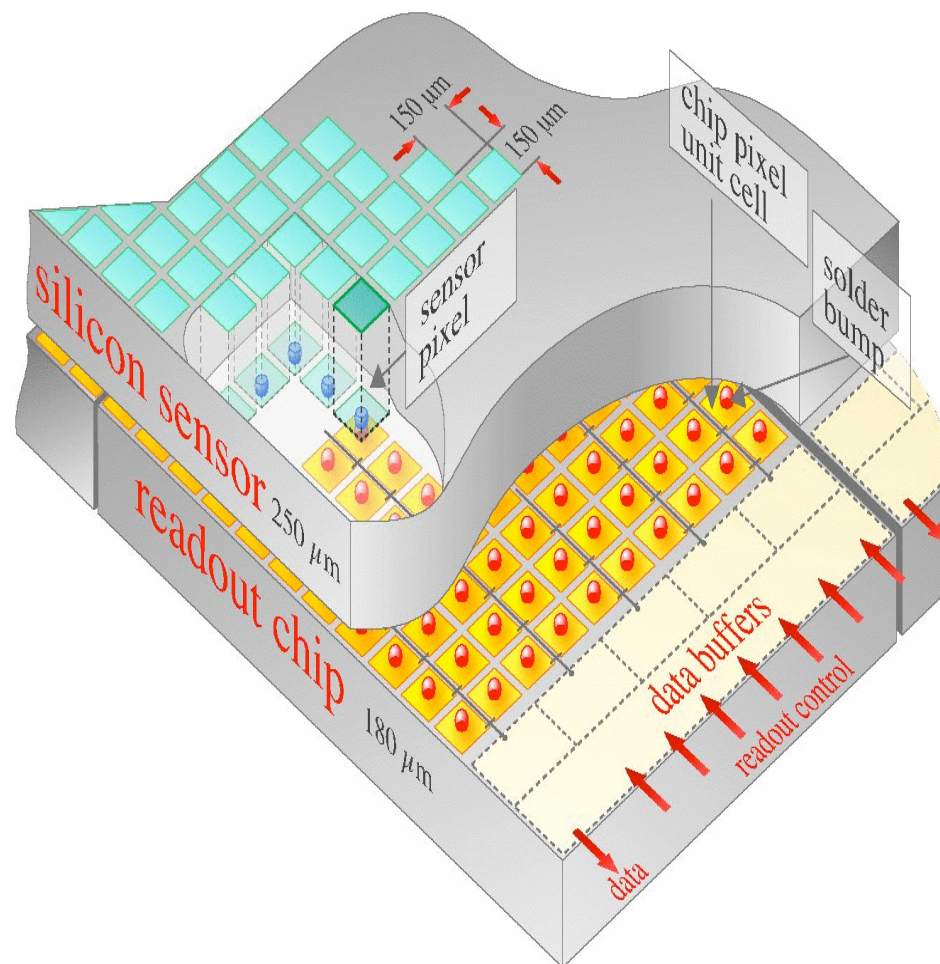
Silicon → see next slide

Readout chips:

0.25 micron CMOS IBM technology

Bump bonding needed to connect the sensor to the Readout chip (ROC)

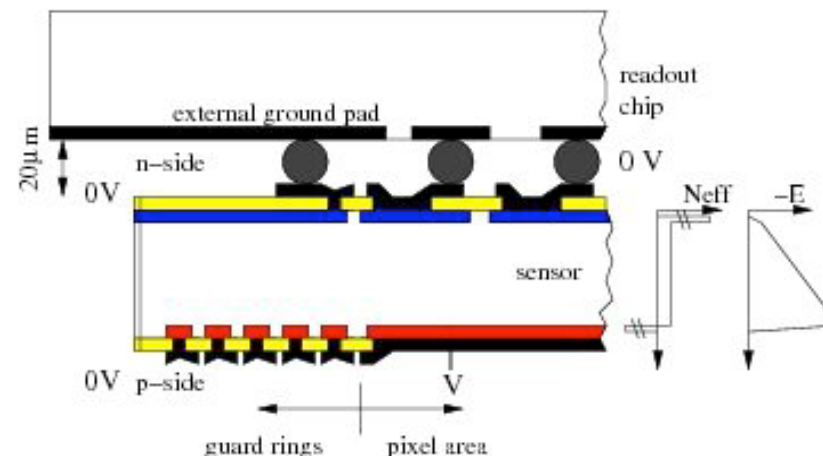
Pixel size: $100\text{ }\mu\text{m} \times 150\text{ }\mu\text{m}$





Sensor choice (n^+ -in-n)

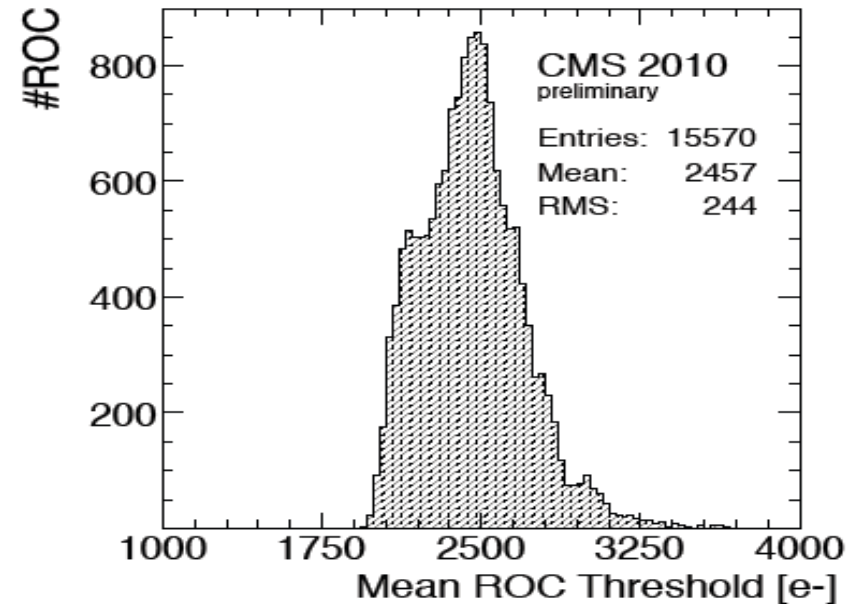
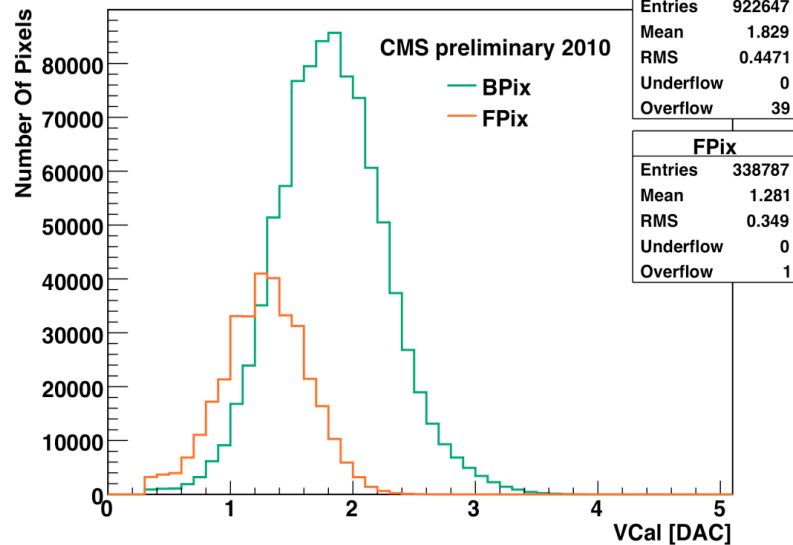
- n^+ implants on n substrate
- p junction on the back side (double sided processing)
 - Collects electrons: higher mobility and larger Lorentz angle
 - Charge trapping is reduced
- **Radiation hardness motivates:**
 - O enriched (FPIX: 100-FZ, BPIX: 111-DOFZ)
 - Guard rings on back side
 - All sensor edges at ground potential
- **Pixel cell layout**
 - Moderated p-spray with bias grid
 - Small gaps (20 μm)





Performance

Noise of Subset



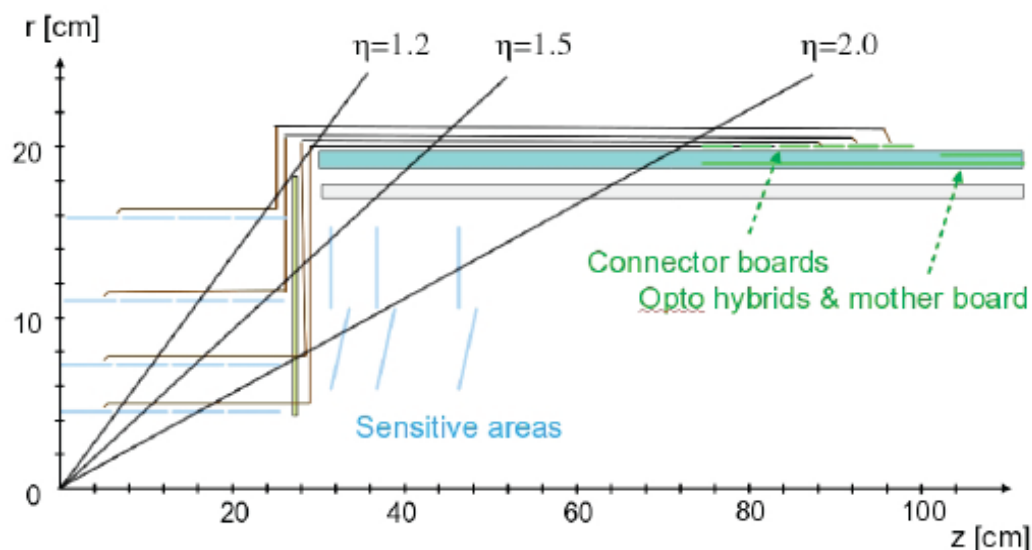
- The expected signal for a MIP is 22000 electrons
- Noise = $1.8 * 65 = 120$ electrons
- The pixel detectors are almost noiseless

- Threshold: 2500 electrons
- Thresholds are much above the pixel noise
- Thresholds are determined by the readout chip internal cross-talk



Pixel upgrade

- **Current** luminosity is more than 1 fb^{-1} . Fluence is about $1.2 \times 10^{12} \text{ n}_{\text{eq}}/\text{cm}^2$
- **Upgrade phase I (2016)**: predicted luminosity 70 fb^{-1} . Fluence $5 \times 10^{14} \text{ n}_{\text{eq}}/\text{cm}^2$
- **Extreme scenario**: luminosity 250 fb^{-1} . Fluence $1.3 \times 10^{15} \text{ n}_{\text{eq}}/\text{cm}^2$



4 barrel layers + 3
endcap disks

- From the sensor point of view, major impact comes from:
 - New cooling system down to -20°C (now running at $+7^\circ\text{C}$)
 - Peak luminosity increase up to $2 \times 10^{34} \text{ cm}^{-2} \text{ s}^{-1}$
 - Possibility of reducing the inner radius currently discussed



Radiation effects

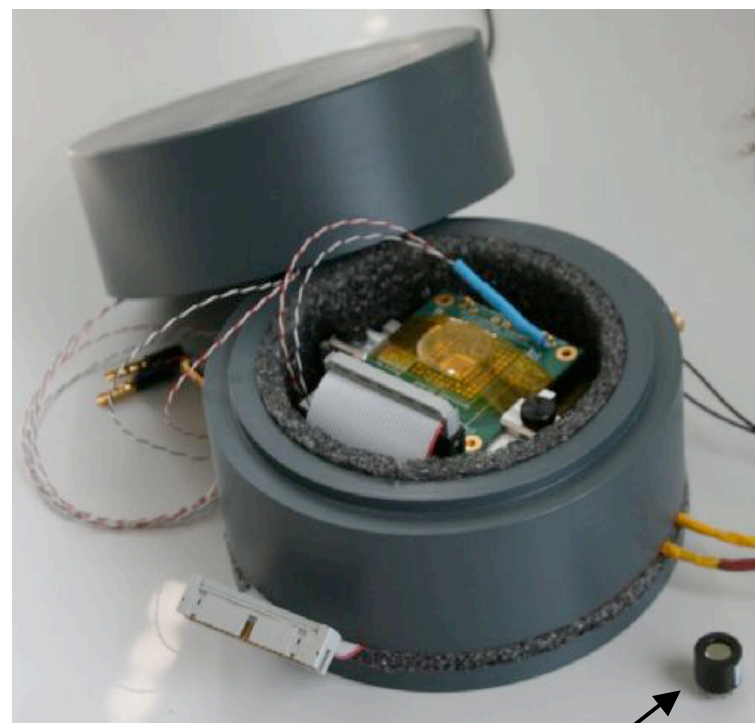
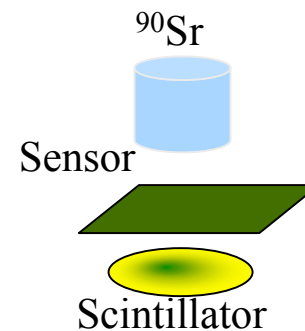
- 1) **Sensor damage** – increased leakage currents
Seen from the beginning in CMS: $1 \text{ fb}^{-1} \rightarrow 0.75 \text{ nA/pixel}$
Potential limits on power supplies $\rightarrow 70 \text{ fb}^{-1}$
 - 2) **Sensor damage** – partial depletion, charge trapping,
need to increase the bias voltage.
Not yet observed in CMS.
 - 3) **ROC (Readout chip) damage** – change of the internal voltages .
Not yet observed in CMS.
- Studies presented here intend to determine at which fluence the effects become a problem.



Testing setup

- Test sensor + readout chip
- Measured charge value obtained from MIP beta particles emitted by ^{90}Sr (products endpoint 2.28 MeV)
- Trigger provided by a scintillator detector
- Samples were cooled through a Peltier to -20°C or -25°C depending on fluence
- Temperature and humidity sensors

Measurements by
Joaquin Siado (UPRM)

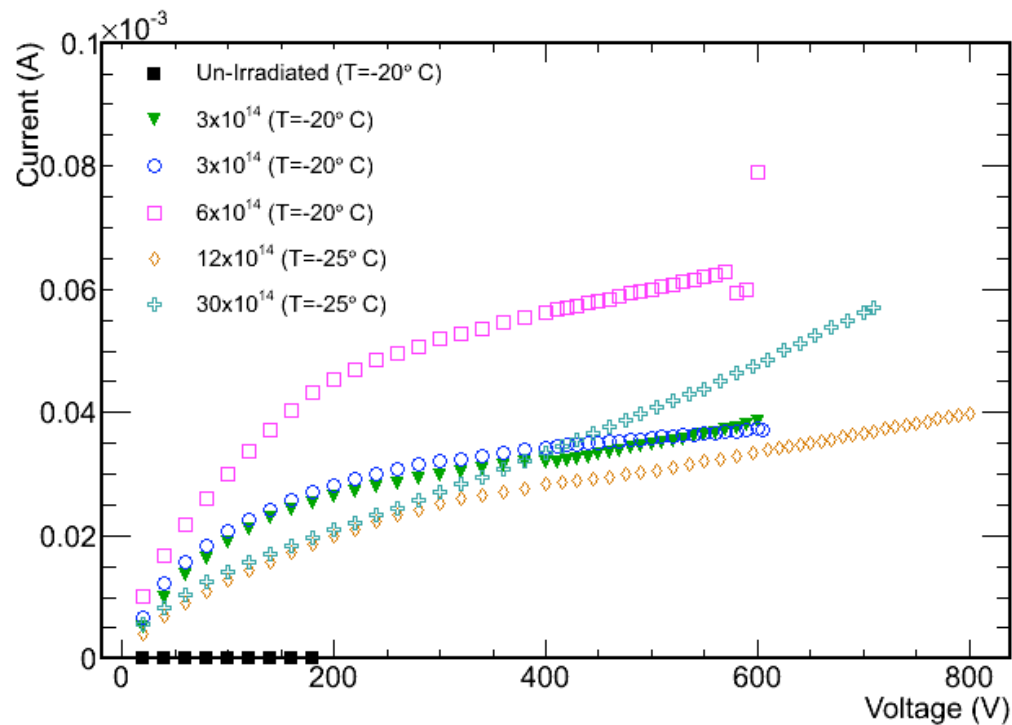


photomultiplier 7



Samples tested

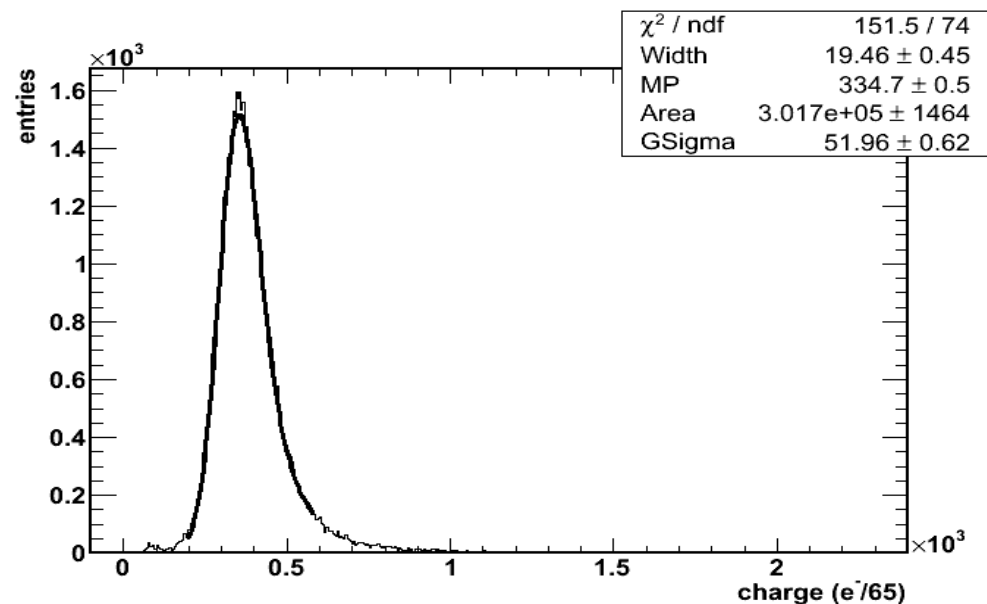
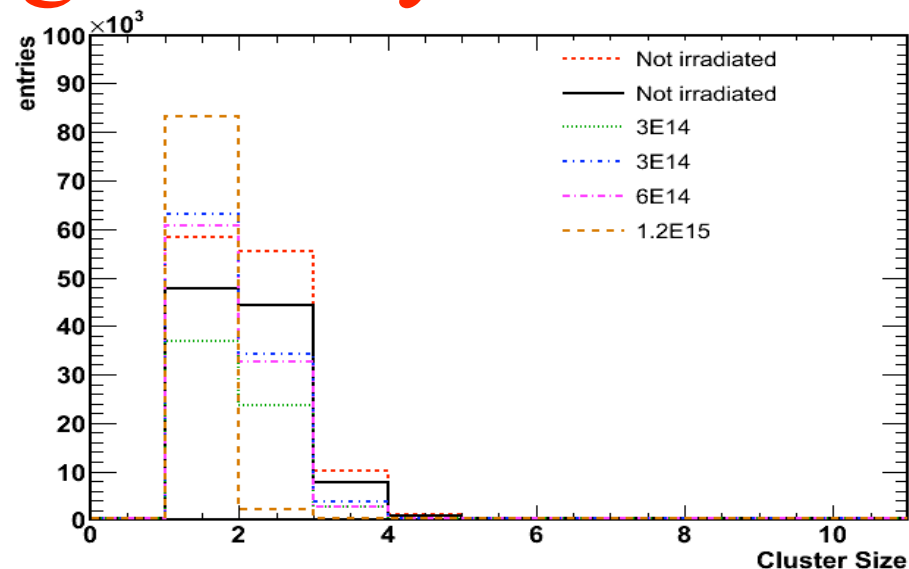
- Samples consisting of sensor + readout chip
- Irradiated with protons (24 MeV) at Karlsruhe in 2010
- Fluences tested:
 - Unirradiated
 - $3 \times 10^{14} \text{ n}_{\text{eq}}/\text{cm}^2$
 - $6 \times 10^{14} \text{ n}_{\text{eq}}/\text{cm}^2 \rightarrow 70 \text{ fb}^{-1}$
 - $12 \times 10^{14} \text{ n}_{\text{eq}}/\text{cm}^2 \rightarrow 250 \text{ fb}^{-1}$
 - $30 \times 10^{14} \text{ n}_{\text{eq}}/\text{cm}^2$ (only partially tested)
- To avoid annealing, samples kept in freezer at -18°C
- Current – voltage curves confirm the goodness of the samples





Signal Height analysis

- Beta-spectrum of ^{90}Sr contains many low energetic particles + multiple scattering
- **Only single pixel clusters are used \rightarrow selects particles going perpendicular to the pixels**
- Cluster size distribution already shows change in efficiency. Absolute efficiency measurement not possible due to multiple scattering
- Fit to the deposited charge distribution as a Landau convoluted with a Gaussian





Signal Height Results

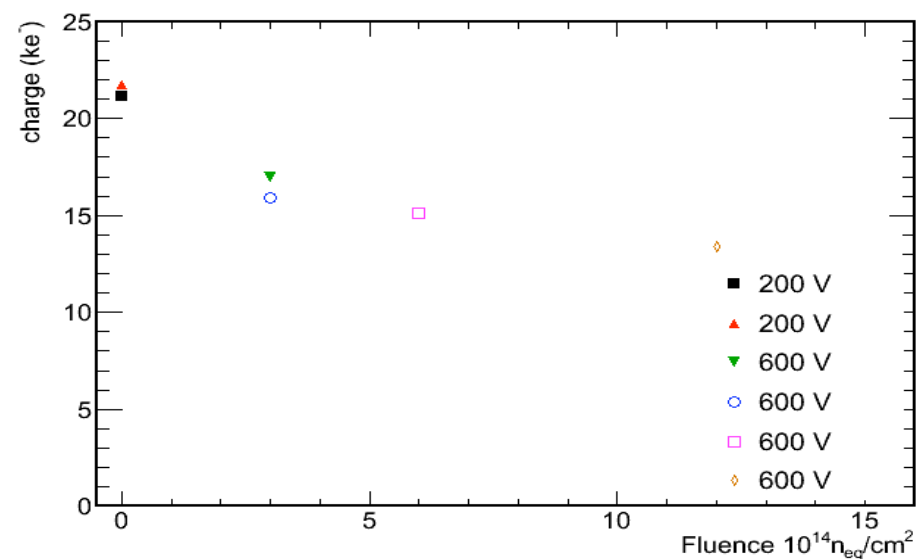
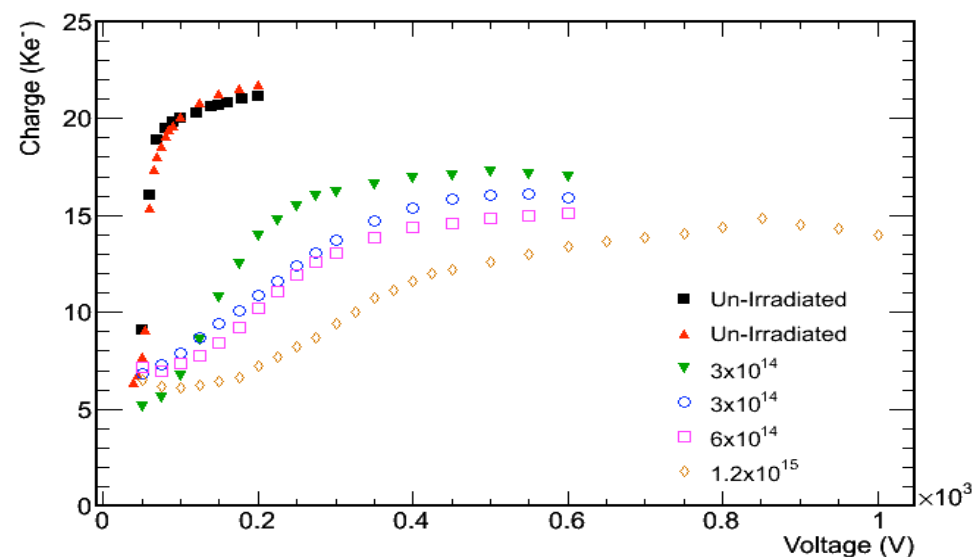
- Results presented here are compatible with T.Rohe et al, NIM A (2010) 624:414-418

- Charge collected is 13000 electrons for $\phi=1.2 \times 10^{15} \text{ n}_{\text{eq}}/\text{cm}^2$ above 600 V

- Highly irradiated sensors operative up to 1000 V

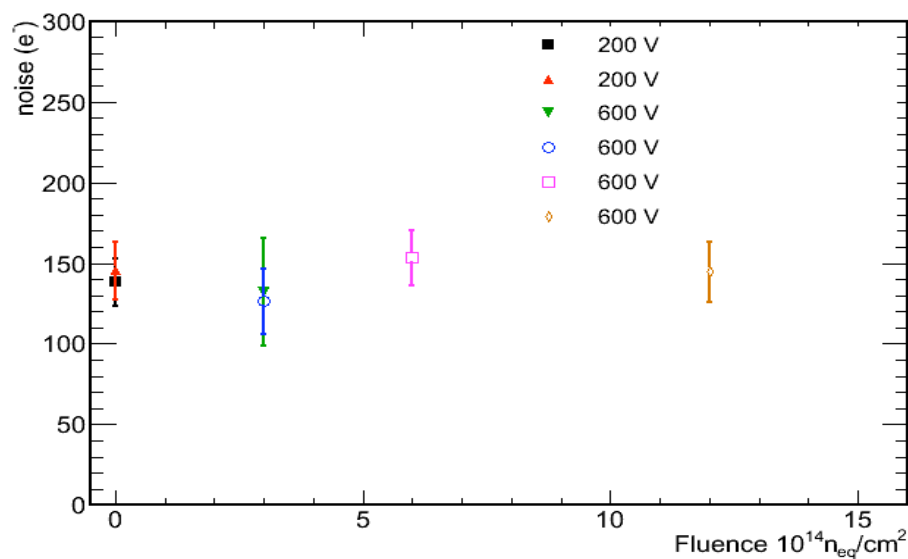
- Such high voltages are currently limited in CMS by connectors, cables and power supplies

- Lorentz angle diminishes at high voltage: effect not addressed here





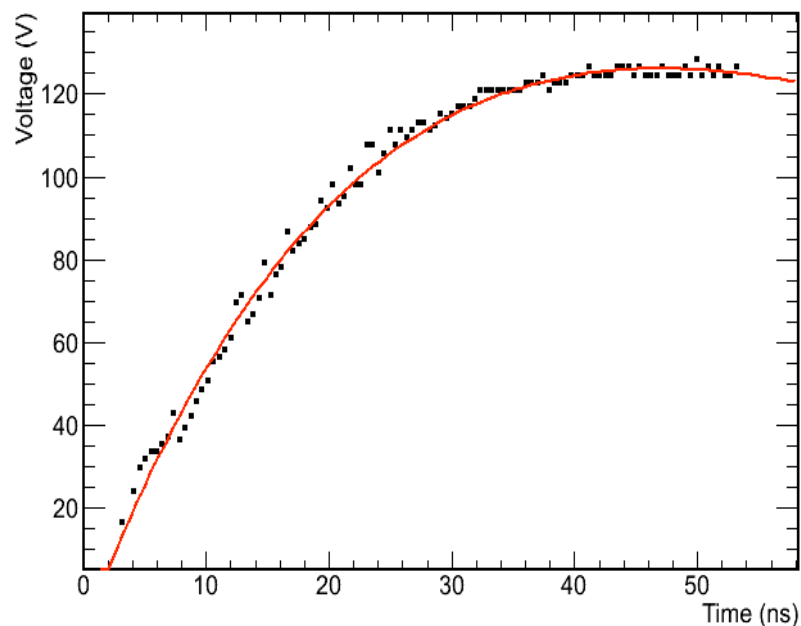
Readout chips at high fluences



- Readout chip functioning with minimal changes to the nominal settings
- Small changes to the preamplifier and shapers feedback circuits applied
- Noise stable even at high irradiation (shown for full depletion or high bias voltage)
- Thresholds set to 3900 electrons in all measurements (low enough compared to charge collected)



Characteristic time measurement



- Leading edge of the preamplifier output is sampled indirectly through a delay scan

- Characteristic time:

- extracted using a fit :

$$PH(t) = p_0 + p_1 \cdot t \cdot e^{-\frac{t}{p_2}}$$

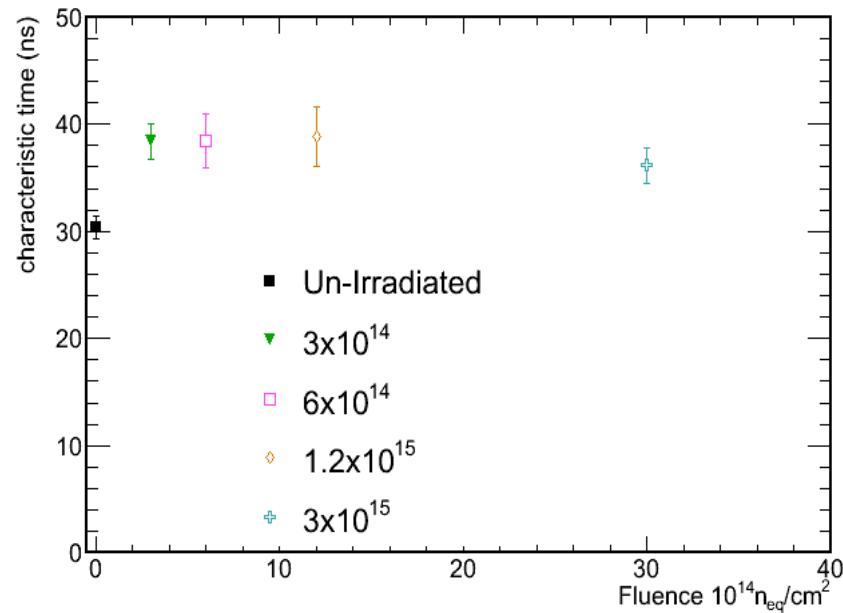
- for unirradiated readout chips **without** sensor is $\approx (27 \pm 1)$ ns

- for unirradiated readout chips **with** sensor is $\approx (30 \pm 1)$ ns

- Sensor adds an extra capacitance in series to the readout chip capacitance



Characteristic time measurement



Radiation ($10^{14} n_{eq}/cm^2$)	time (ns)
0	30±1
3	38±2
6	39±3
12	39±3
30	36±2

- Characteristic time increases with fluence. Quite flat for irradiated samples
- Specific tests still need to be performed to:
 - Determine if the main effect comes from a saturation given by the capacitance of the sensor
 - Detangle the effect of the radiation damage on the readout chip
 - Recover the characteristic time by changing the analog current



Conclusions

- Present CMS sensor and readout chips have been tested up to fluences of $1.2 \times 10^{15} \text{ n}_{\text{eq}}/\text{cm}^2 \rightarrow 250 \text{ fb}^{-1}$
- Charge collected is >13000 electrons when bias voltage $>600 \text{ V}$ even for fluences of $10^{15} \text{ n}_{\text{eq}}/\text{cm}^2$
- Readout chip does not manifest major changes up to the tested fluences
- Leakage current may limit current CMS inner pixel layer lifetime to 70/fb: still enough up to upgrade phase I
- Pixel upgrade will not suffer from leakage current so much as operating temperature will change $+7^\circ\text{C} \rightarrow -20^\circ\text{C}$ (exponential effect)



Leakage current – CMS pixels (Layer 1)

